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APPLICATION NO). 1	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/508,924		09/24/2004	Makoto Motoyoshi	075834.00325	8150
33448	7590	11/29/2006		EXAMINER	
ROBERT	J. DEPKI	Е	NGUYEN, TRAM HOANG		
LEWIS T.					
ROCKEY,	, DEPKE, I	LYONS AND KITZI	ART UNIT	PAPER NUMBER	
SUITE 54:	SUITE 5450 SEARS TOWER			2818	
CHICAGO	CHICAGO, IL 60606-6306				

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)					
	10/508,924	MOTOYOSHI ET AL.					
Office Action Summary	Examiner	Art Unit					
	Tram H. Nguyen	2818					
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet v	vith the correspondence add	ress				
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Status							
1) Responsive to communication(s) filed on 24 /							
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·	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
closed in accordance with the practice under	Lx parte Quayre, 1955 C.	D. 11, 400 O.O. 210.					
Disposition of Claims			,				
4) ⊠ Claim(s) <u>1-38</u> is/are pending in the application 4a) Of the above claim(s) <u>20-38</u> is/are withdra 5) ⊠ Claim(s) <u>9-13</u> is/are allowed. 6) ⊠ Claim(s) <u>1-8 and 14-19</u> is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/	awn from consideration.						
Application Papers							
9) The specification is objected to by the Examir	ner.						
10)☐ The drawing(s) filed on is/are: a)☐ ac							
Applicant may not request that any objection to the			D 4 404(J)				
Replacement drawing sheet(s) including the corre							
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Bure * See the attached detailed Office action for a list	nts have been received. nts have been received in fority documents have bee au (PCT Rule 17.2(a)).	Application No en received in this National S	Stage				
Attachment(s)							
1) Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) A) Interview Summary (PTO-413) Paper No(s)/Mail Date							
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 05/01/2006. 		f Informal Patent Application					

DETAILED ACTION

Election/Restrictions

During Applicant's interview on 11/06/2006 has been carefully considered by the examiner. The arguments advanced therein are persuasive with respect to the restriction of record and those election/restriction is accordingly withdrawn. Group I, species A, claims 1-19 are pending in this application.

Specification

The lengthy specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

⁽b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

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Claims 1-8,14-19 are rejected under 35 U.S.C. 102(b) as being anticipated by Saito et al. (US 2002/0034094; hereinafter refer to Saito).

Regarding **claim 1**, Saito discloses a nonvolatile magnetic memory device of the type having: a first wiring (item 15); a second wiring (item 16) intersecting three-dimensionally with said first wiring (see fig. 9A); and a tunnel magnetoresistance element (item 13) which is electrically insulated from said first wiring (15) and electrically connected to said second wiring (16) and which is formed in the region of intersection of said first wiring (15) and said second wiring (16) such that a tunnel insulating layer item 22) is sandwiched between ferromagnetic materials (items 21/23) which change in resistance depending on whether the spin direction is parallel or antiparallel, thereby recording information; wherein said magnetic memory device comprises a magnetic flux concentrator of high-permeability layer (item 18) formed at least on the lateral sides of said first wiring (item 15) and on the side of said first wiring (15) which is opposite to the side facing said tunnel magnetoresistance element(13), with at least either of said high-permeability layer formed on the lateral sides of said first wiring projecting from said first wiring toward said tunnel magnetoresistance element (see fig. 10).

Regarding **claim 2**, Saito discloses all the limitations of the claimed invention for the same reasons as set forth above. Besides, Fig. 10 shows the magnetic flux concentrator (18) has the high-permeability layer formed also on the surface of the first wiring close to the tunnel magnetoresistance element.

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Regarding **claim 3**, Saito discloses all the limitations of the claimed invention for the same reasons as set forth above. Besides, Fig. 10 shows an insulating film (19) is formed between the magnetic flux concentrator (18) and the first wiring (15).

Regarding **claim 4**, Saito discloses all the limitations of the claimed invention for the same reasons as set forth above. Besides, Fig. 10 shows wherein the magnetic flux concentrator (18) has the high-permeability layer formed, with an insulating film (19) interposed, also on the surface of the first wiring (18) close to the tunnel magnetoresistance element (13).

Regarding **claim 5**, Saito discloses a nonvolatile magnetic memory device of the type having: a first wiring (16); a second wiring (15) intersecting three-dimensionally with said first wiring (see fig. 9A); and a tunnel magnetoresistance element (item 13) which is electrically insulated from said first wiring (16) and electrically connected to said second wiring (see fig. 9A) and which is formed in the region of intersection of said first wiring and said second wiring such that a tunnel insulating layer (item 22) is sandwiched between ferromagnetic materials (items 21/23) which change in resistance depending on whether the spin direction is parallel or antiparallel, thereby recording information (see fig. 9A); wherein said magnetic memory device comprises a magnetic flux concentrator of high-permeability layer (item 18) formed at least on the lateral sides of said second wiring (item 15) and on the side of said second wiring (15) which is opposite to the side facing said tunnel magnetoresistance element (13), with at least either of said high-permeability layer formed on the lateral sides of said second wiring

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projecting from said second wiring toward said tunnel magnetoresistance element (see fig. 10).

Regarding **claim 6**, Saito discloses all the limitations of the claimed invention for the same reasons as set forth above. Besides, Fig. 10 shows the magnetic flux concentrator (18) has the high-permeability layer formed also on the surface of the second wiring close to the tunnel magnetoresistance element.

Regarding **claim 7**, Saito discloses all the limitations of the claimed invention for the same reasons as set forth above. Besides, Fig. 10 shows an insulating film (19) is formed between the magnetic flux concentrator (18) and the second wiring (15).

Regarding **claim 8**, Saito discloses all the limitations of the claimed invention for the same reasons as set forth above. Besides, Fig. 10 shows the magnetic flux concentrator (18) has the high-permeability layer formed, with an insulating film interposed, also on the surface of the second wiring (15) close to the tunnel magnetoresistance element (13).

Regarding claim 14, Saito discloses a nonvolatile magnetic memory device of the type having: a first wiring (16); a second wiring (15) intersecting three-dimensionally with said first wiring (see fig. 9A); and a tunnel magnetoresistance element (13) which is electrically connected to said first wiring (16) through a switching element and is electrically connected to said second wiring and which is formed in the region of intersection of said first wiring and said second wiring such that a tunnel insulating layer is sandwiched between ferromagnetic materials which change in resistance depending

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on whether the spin direction is parallel or antiparallel, thereby recording information (see fig. 9A); wherein said magnetic memory device comprises a magnetic flux concentrator of high-permeability layer (18) formed at least on both of the lateral sides of said first wiring (15) and on the side of said first wiring which is opposite to the side facing said tunnel magnetoresistance element (13), with at least either of said high-permeability layer formed on the lateral sides of said first wiring (15) projecting from said first wiring toward said tunnel magnetoresistance element (see fig. 10).

Regarding **claim 15**, Saito discloses all the limitations of the claimed invention for the same reasons as set-forth above. Besides, Fig. 10 shows an insulating film (19) is formed between the magnetic flux concentrator (18) and the tunnel magnetoresistance element (13).

Reagarding claim 16, Saito disclose a nonvolatile magnetic memory device of the type having: a first wiring (16); a second wiring (15) intersecting three-dimensionally with said first wiring (see fig. 9A); and a tunnel magnetoresistance element(13) which is electrically connected to said first wiring (16) through a switching element and is electrically connected to said second wiring (15) and which is formed in the region of intersection of said first wiring (16) and said second wiring (15) such that a tunnel insulating layer (22) is sandwiched between ferromagnetic materials (21/23) which change in resistance depending on whether the spin direction is parallel or antiparallel, thereby recording information (see fig. 9A); wherein said magnetic memory device comprises a magnetic flux concentrator of high-permeability layer (18) formed at least on both of the lateral sides of said second wiring (16) and on the side of said second

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wiring (16) which is opposite to the side facing said tunnel magnetoresistance element (13), with at least either of said high-permeability layer formed on the lateral sides of said second wiring projecting from said second wiring toward said tunnel magnetoresistance element (see fig. 10).

Regarding **claim 17**, Saito discloses all the limitations of the claimed invention for the same reasons as set-forth above. Besides, Fig. 10 shows the magnetic flux concentrator (18) has the high-permeability layer formed also on the surface of the second wiring close to the tunnel magnetoresistance element.

Regarding **claim 18**, Saito discloses all the limitations of the claimed invention for the same reasons as set-forth above. Besides, Fig. 10 shows wherein an insulating film (19) is formed between the magnetic flux concentrator (18) and the second wiring (15).

Regarding **claim 19**, Saito discloses all the limitations of the claimed invention for the same reasons as set-forth above. Besides, Fig. 10 shows the magnetic flux concentrator (18) has the high-permeability layer formed, with an insulating film interposed, also on the surface of the second wiring close to the tunnel magnetoresistance element.

Allowable Subject Matter

Claims 9-13 are allowable over the prior art of record because none of these references disclose or can be combined to yield the claimed invention such as "the magnetic memory device comprises a magnetic flux concentrator of high-permeability

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layer formed between said first wiring and said tunnel magnetoresistance element and on the lateral sides of said tunnel magnetoresistance element, with an insulating film interposed" in claim 8 and the "magnetic memory device comprises a first magnetic flux concentrator of high-permeability layer formed at least on both of the lateral sides of said first wiring and on the side of said first wiring which is opposite to the side facing said tunnel magnetoresistance element and a second magnetic flux concentrator of high-permeability layer formed between said first wiring and said tunnel magnetoresistance element and on the lateral sides of said tunnel magnetoresistance element, with an insulating film interposed" in claim 10.

Conclusion

When responding to the office action, Applicants are advised to provide the examiner with the line numbers and page numbers in the application and/or references cited to assist the examiner to locate the appropriate paragraphs.

A shortened statutory period for response to this action is set to expire 3 (three) months and 0 (zero) day from the day of this letter. Failure to respond within the period for response will cause the application to become abandoned (see M.P.E.P 710.02(b)).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tram Hoang Nguyen whose telephone number is (571) 272-5526. The examiner can normally be reached on Monday-Friday 9:00am - 6:00pm.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mathew Smith can be reached on (571) 272-1907. The fax numbers for all Customer Service is (571) 273-8300.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (571)272-1625.

THN Art Unit 2818 Date Andy Hugh Brimary Examiner